

WEST**Structured Search****Database:**

US Patents Full-Text Database
 US Pre-Grant Publication Full-Text Database
 JPO Abstracts Database
 EPO Abstracts Database
 Derwent World Patents Index
 IBM Technical Disclosure Bulletins

Searchable Index:

<none> - All Fields

Not Numeric

Term 1 text:**Operator:**

AND

Proximity Distance:

1

Searchable Index:

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Not Numeric

Term 2 text:**Display:**

10

Documents in **Display Format:**

CIT

Starting With #:

1

Generate:
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 ☐ Side by Side
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DATE: Wednesday, December 04, 2002 [Printable Copy](#) [Create Case](#)
Set Name Query

side by side

Hit Count Set Name

result set

*DB=USPT; PLUR=YES; OP=ADJ*L44 L43 and (thermal or temperature)

187

L44L43 (L3 and (edge or gap))

398

L43*DB=EPAB; PLUR=YES; OP=ADJ*L42 L40 and (thermal or temperature)

13

L42L41 L40 and (edge or gap)

1

L41L40 ((G03F007/42)!.IPC.)

124

L40*DB=JPAB; PLUR=YES; OP=ADJ*L39 L38 and (gap or edge)

43

L39

<u>L38</u>	((G03F007/42)!.IPC.)	748	<u>L38</u>
<i>DB=EPAB; PLUR=YES; OP=ADJ</i>			
<u>L37</u>	L36 and (edge or gap)	55	<u>L37</u>
<u>L36</u>	((H01L021/306)!.IPC.)	912	<u>L36</u>
<i>DB=JPAB; PLUR=YES; OP=ADJ</i>			
<u>L35</u>	L34 and (temperature or thermal)	51	<u>L35</u>
<u>L34</u>	L33 and (edge or gap)	547	<u>L34</u>
<u>L33</u>	((H01L021/306)!.IPC.)	7599	<u>L33</u>
<u>L32</u>	L31 and gap	12	<u>L32</u>
<u>L31</u>	(G03F007/42)	748	<u>L31</u>
<u>L30</u>	(G03F 07/42)	0	<u>L30</u>
<u>L29</u>	(G03F7/42)	0	<u>L29</u>
<u>L28</u>	(G03F07/42)	0	<u>L28</u>
<u>L27</u>	((G03F7/42)!.IPC.)	0	<u>L27</u>
<u>L26</u>	L25 and (spinning or spinner)	21	<u>L26</u>
<u>L25</u>	L24 and washing	800	<u>L25</u>
<u>L24</u>	resist or photoresist	66867	<u>L24</u>
<u>L23</u>	((134/33)!.CCLS.)	20	<u>L23</u>
<i>DB=EPAB; PLUR=YES; OP=ADJ</i>			
<u>L22</u>	((134/33)!.CCLS.)	2	<u>L22</u>
<u>L21</u>	L20 and (temperature or gap or edge)	34	<u>L21</u>
<u>L20</u>	L19 and (solvent or etchant or etching)	224	<u>L20</u>
<u>L19</u>	L18 and (removal or removing)	572	<u>L19</u>
<u>L18</u>	resist or photoresist	5864	<u>L18</u>
<u>L17</u>	unnecessary film	3	<u>L17</u>
<u>L16</u>	((118/56)!.CCLS.)	10	<u>L16</u>
<u>L15</u>	((118/52)!.CCLS.)	13	<u>L15</u>
<u>L14</u>	L13 and (chuck or coater)	17	<u>L14</u>
<u>L13</u>	spinner or spinning	5700	<u>L13</u>
<i>DB=JPAB; PLUR=YES; OP=ADJ</i>			
<u>L12</u>	L11 and gap	6	<u>L12</u>
<u>L11</u>	L10 and (chuck or coater)	268	<u>L11</u>
<u>L10</u>	spinning or spinner	19087	<u>L10</u>
<u>L9</u>	L6 and gap	16	<u>L9</u>
<u>L8</u>	L6 and (temperature or thermal)	45	<u>L8</u>
<u>L7</u>	L6 and edge	50	<u>L7</u>
<u>L6</u>	L3 or L4	414	<u>L6</u>

L5 ((118/56)!.CCLS.)

28 L5

L4 ((118/52)!.CCLS.)

414 L4

DB=USPT; PLUR=YES; OP=ADJ

L3 L1 or L2

956 L3

L2 ((118/56)!.CCLS.)

445 L2

L1 ((118/52)!.CCLS.)

632 L1

END OF SEARCH HISTORY